



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Batch/Confirmation No.: 8988

Christian G. VAN DE WALLE

Allowed:

May 19, 2003

Group Art Unit: 2814

Application No.: 09/682,174

Examiner:

L. Pham

Filed:

July 31, 2001

Docket No.: 108901

For:

SEMICONDUCTOR STRUCTURES HAVING REDUCED CONTACT

RESISTANCE

LETTER TO THE OFFICIAL DRAFTSPERSON

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Please substitute the attached $\underline{4}$ sheets of formal drawings depicting Figures $\underline{1-8}$ for the corresponding drawings filed with the application. The attached drawings have been corrected pursuant to the Notice re Patent Drawings attached to Paper No. 10 requiring drawing correction complying with June 18, 2002 issued PTO-948 attached to paper No. 2.

Respectfully submitted,

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Date: June 19, 2003

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